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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/717,122	11/19/2003	Larry Zhao	2000.106900	7303
23720	7590 08/10/2005		EXAM	INER
	, MORGAN & AMER	GHYKA, ALI	EXANDER G	
10333 RICHMOND, SUITE 1100 HOUSTON, TX 77042			ART UNIT	PAPER NUMBER
noobron,	111 77012		2812	

DATE MAILED: 08/10/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	
	10/717,122	ZHAO ET AL.	
Office Action Summary	Examiner	Art Unit	
	Alexander G. Ghyka	2812	
The MAILING DATE of this communication Period for Reply	appears on the cover sheet with	the correspondence address	
A SHORTENED STATUTORY PERIOD FOR RE THE MAILING DATE OF THIS COMMUNICATIO - Extensions of time may be available under the provisions of 37 CFF after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a - If NO period for reply is specified above, the maximum statutory per - Failure to reply within the set or extended period for reply will, by state of the period for reply will be period for reply will be stated for the period for the pe	N. R 1.136(a). In no event, however, may a repl reply within the statutory minimum of thirty (3 riod will apply and will expire SIX (6) MONTH atute, cause the application to become ABAN	y be timely filed 30) days will be considered timely. S from the mailing date of this communication. IDONED (35 U.S.C. § 133).	
Status			
Responsive to communication(s) filed on This action is FINAL. 2b)⊠ T Since this application is in condition for allocation closed in accordance with the practice under	his action is non-final. wance except for formal matters	•	
Disposition of Claims			
4) Claim(s) 10-31 is/are pending in the application Papers 4) Claim(s) 10-31 is/are allowed. 5) Claim(s) 10-31 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction an are subject to by the Example 10) The drawing(s) filed on 19 November 2003 is Applicant may not request that any objection to the Replacement drawing sheet(s) including the corrections.	drawn from consideration. d/or election requirement. hiner. is/are: a)⊠ accepted or b)□ o the drawing(s) be held in abeyance	. See 37 CFR 1.85(a).	
11) The oath or declaration is objected to by the		•	
Priority under 35 U.S.C. § 119			
 12) Acknowledgment is made of a claim for fore a) All b) Some * c) None of: 1. Certified copies of the priority documents. 2. Certified copies of the priority documents. 3. Copies of the certified copies of the papplication from the International Bures. * See the attached detailed Office action for a second common seco	ents have been received. ents have been received in App priority documents have been re reau (PCT Rule 17.2(a)).	lication No ceived in this National Stage	
Attachment(s)	,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,		
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/Paper No(s)/Mail Date 	Paper No(s)/N	4) Interview Summary (PTO-413) Paper No(s)/Mail Date 5) Notice of Informal Patent Application (PTO-152) 6) Other:	

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DETAILED ACTION

Claims 1-9 are cancelled. Claims 10-31 are now under consideration.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 10-31 are rejected under 35 U.S.C. 102(e) as being anticipated by Rajagopalan (US 6,656,840).

The present claims generally require forming a first silicon nitride layer on an exposed copper surface; and forming a second silicon nitride layer on the first silicon nitride layer while adjusting a silicon concentration of the second silicon nitride layer to be higher than that of the first silicon nitride layer.

Rajagolan et al disclose forming a copper structure on a surface; forming a first layer which comprises a silicon nitride layer; and forming a second silicon nitride layer wherein the the atomic ratio of nitrogen to silicon in the first layer is greater than the atomic ratio of nitrogen to silicon in the second layer, or in other words the second layer is silicon rich. See column 14, lines 30-40. Rajagolan et al disclose the nitride layers are

formed using plasma enhanced chemical vapor without interrupting vacuum as required by present Claim 11. See Example, column 13-14 and column 14, lines 45-50. Moreover, Rajagolan et al discloses using silane and nitrogen without ammonia to form the first layer, and silane and nitrogen without ammonia to form the second nitride layer, wherein the molar ratio of nitrogen to silane in the first layer is greater than the nitrogen to silane in the second layer, as required by present claims 12-17. See the Example on columns 13-14 and column 14, lines 53-60. Ammonia can be used in forming the second layer. See column 11, lines 20-45. Rajagolan also discloses thicknesses of the layers as required by Claims 18-19. See column 5, lines 25-35. The formation of the second layer inherently stops the formation of the first layer as required by claims 23-26. Furthermore, the plasma is not interrupted as required by claims 27-31. See columns 13-14, the Example. Therefore, Claims 10-31 are anticipated by Rajagolan et al.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Alexander G. Ghyka whose telephone number is (571) 272-1669. The examiner can normally be reached on Monday through Thursday during general business hours.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Lebentritt can be reached on (571) 272-1873. The fax phone

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number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

AGG August 7, 2005

> ALEXANDER GHYKA PRIMARY EXAMINER

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